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 H05B 33/00

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 (43)

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 (22) 2003 03 04

(30) JP-P-2002-00057166 2002 03 04 (JP)

(71) 가 가
 2 5 5

(72) 8-41-7

(74)

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(54)

EL
 . . , . , EL
 가 . (22) . (22) (22)
 . (23), (23), (24), (24), (25) (25) (26)
 . . , (24) (24) (26) S1 (22)
 S0 (22)

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, , ,

1	1
2	1
3	1

4 1
5 1
6 2
7 2
8 2
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10 2
11 2
12 2
13 3
14 3
15 EL
16 13 B-B
17 EL

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20A :

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26 :

30 : 1 TFT

40 : 2 TFT

130 :

131 :

132 :

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,
LCD (Electro Luminescence : , 「EL」) EL 가 CRT
(Thin Film Transistor : , 「TFT」) EL .
15 EL (11) , (51) , (52) , 16 (52) , 15 B-B EL (51) TFT
. TFT EL (61) . EL .
, (110) (10) SiO₂ SiN , (10) TFT (1)
0) TFT EL , (10) SiO₂ SiN , (10) TFT .
, (10) (Cr) (13) (11) ,
(12), p-Si (13) (11) (13c) , (13c) (13c) (14)
(13) (11) (13s) (13d) . , (11) LDD(Lightly Do
ped Drain) .

, (12), (13) (14) SiO₂, SiN SiO₂
 (15) , (13d) Al (16) (17)
 , (17) (13s) (13s)
 ITO(Indium Tin Oxide) (18) , (61) , (61) (17)
 (61) ITO(Indium Tin Oxide) (60) EL (60)
 EL (60) , (61), MTDATA(4, 4-bis(3-methylphenylphenylamino) biphenyl)
 1 , TPD (4, 4, 4-tris(3-methylphenylphenylamino) triphenylaniline) 2
 (62), (Quinacridone) Bebq2(10- [h)
) (63), Bebq2 (64),
 (65)

11-283182

EL (60) , S S0 16 EL (60) (61) (63) . , S
, EL (60) , 가 가 . , 17 EL (60)
EL (60) . , . , EL (60) (60) ,

Fl

L

EL , 가 EL , EL , E

, EL (概說)

(1)

(57)

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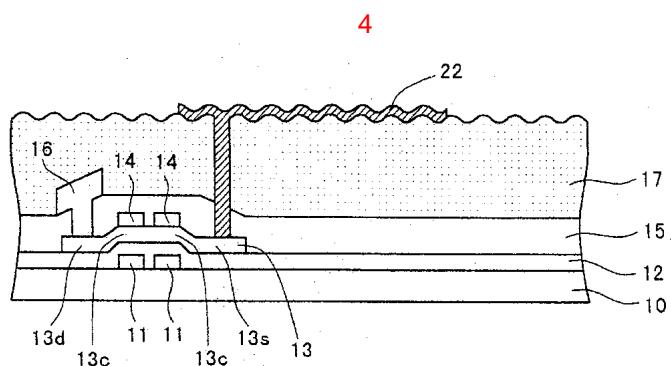
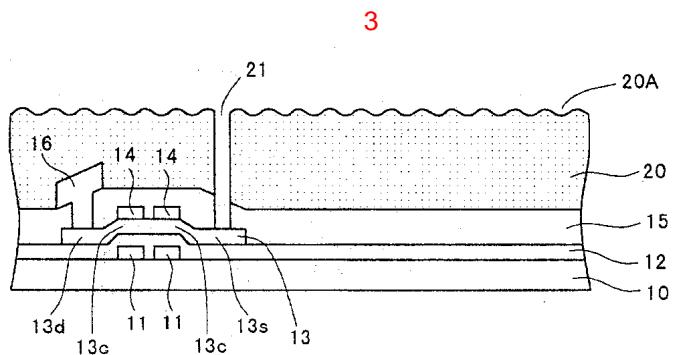
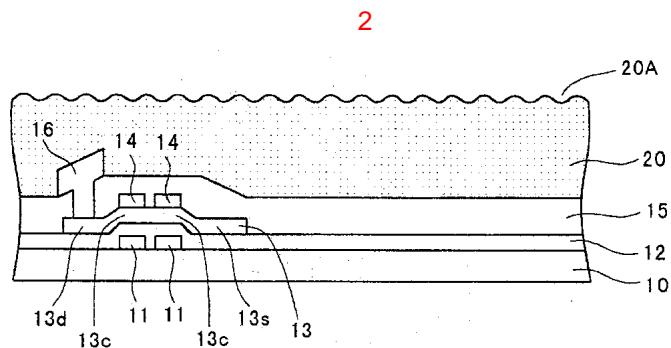
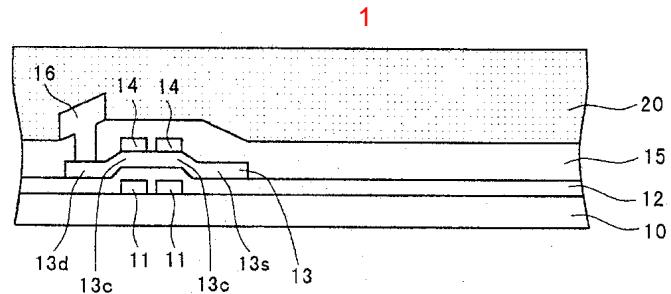
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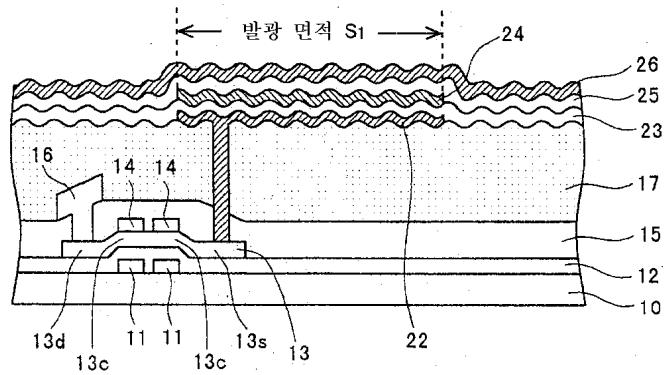
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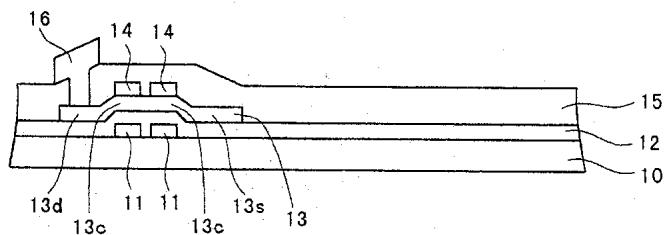
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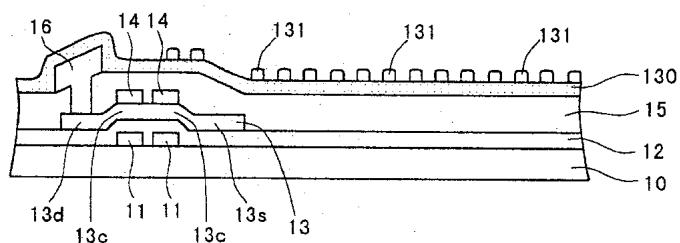
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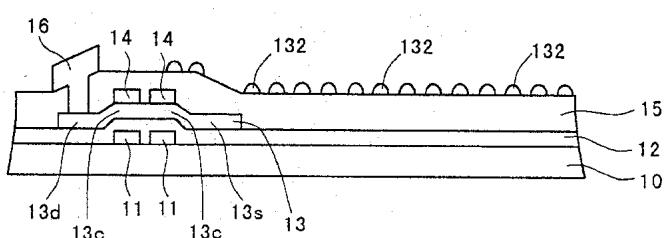
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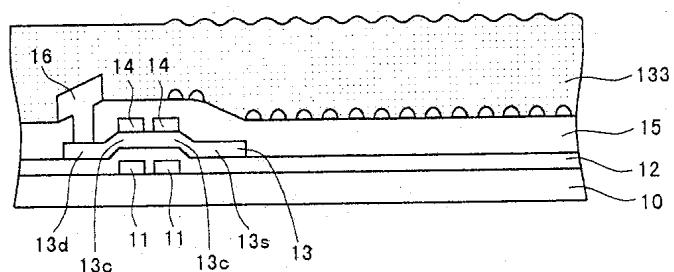
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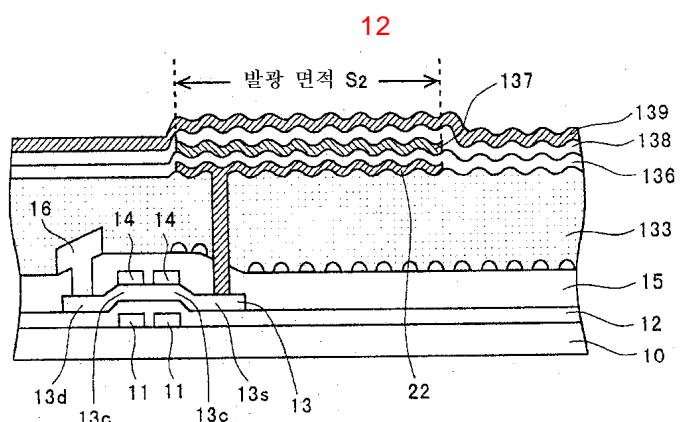
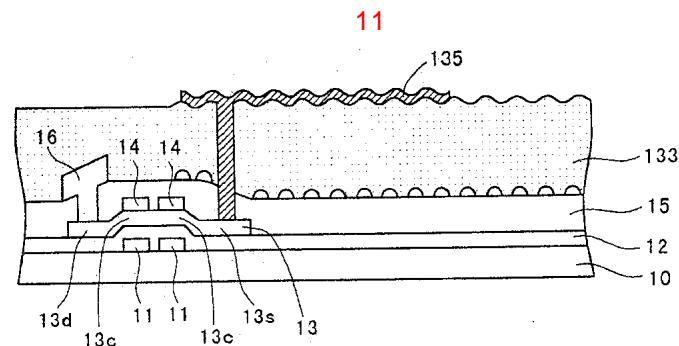
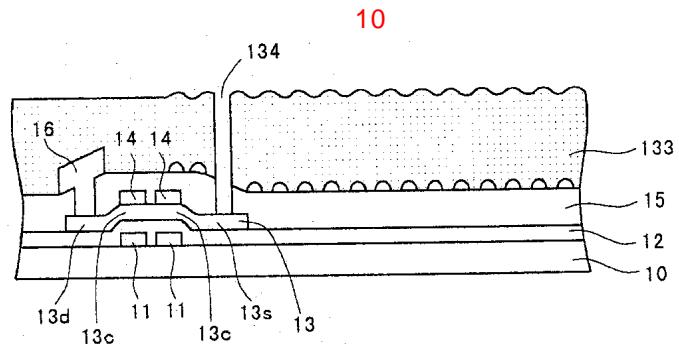


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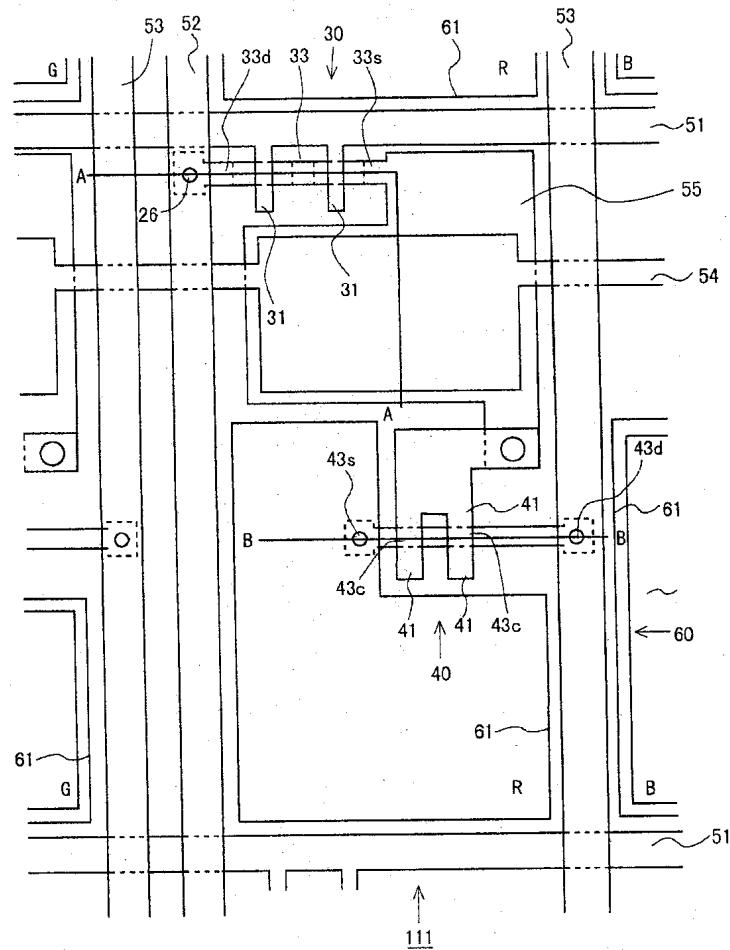


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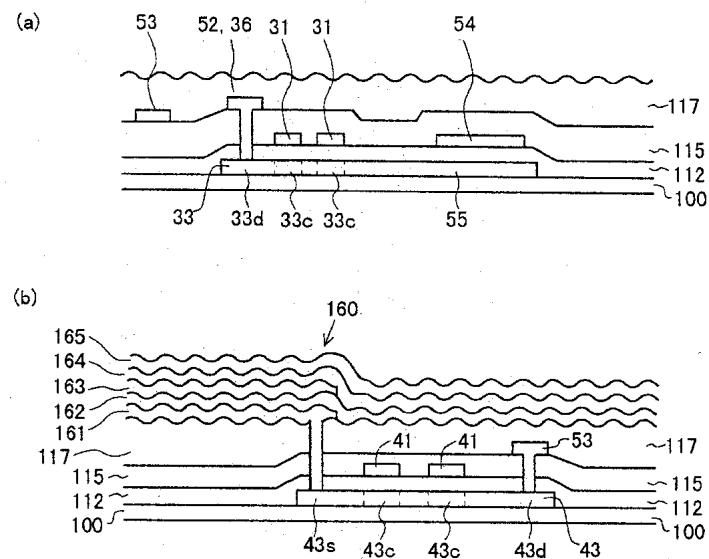




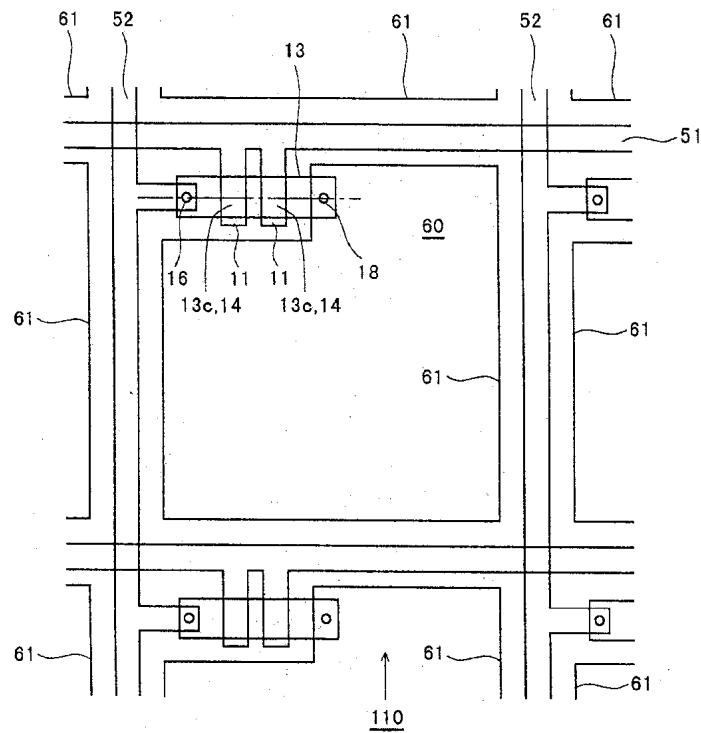
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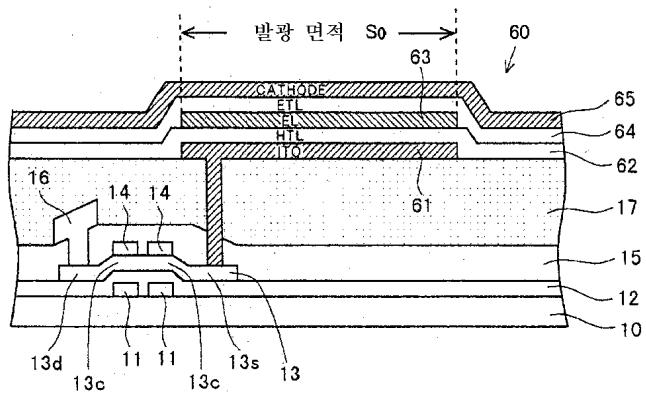
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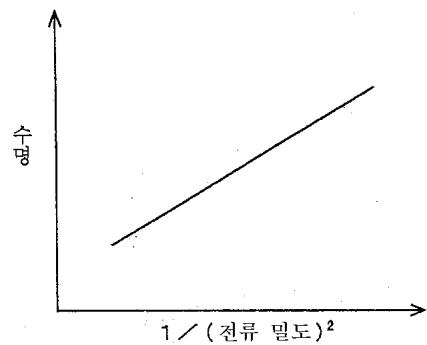
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专利名称(译)	电致发光显示装置及其制造方法		
公开(公告)号	KR1020030072247A	公开(公告)日	2003-09-13
申请号	KR1020030013306	申请日	2003-03-04
[标]申请(专利权)人(译)	三洋电机株式会社 山洋电气株式会社		
申请(专利权)人(译)	三洋电机有限公司是分租		
当前申请(专利权)人(译)	三洋电机有限公司是分租		
[标]发明人	NISHIKAWA RYUJI		
发明人	NISHIKAWA,RYUJI		
IPC分类号	H01L27/32 H01L51/50 H01L51/52 H05B33/00 H05B33/26 H05B33/10		
CPC分类号	H01L51/5262 H01L51/5203 H01L27/3258 H05B33/26 H01L51/5209		
代理人(译)	LEE , JUNG HEE CHU , 晟敏		
优先权	2002057166 2002-03-04 JP		
其他公开文献	KR100564197B1		
外部链接	Espacenet		

摘要(译)

电致发光单元的有效发射面积增加。实现高亮度。而且，在保持电致发光元件的发光亮度的同时延长寿命。凹凸形成在平坦化绝缘层(22)的表面上。平坦化绝缘层(22)的凹凸的不平坦部分被反射形成在阳极(22)的表面上。空穴传输层(23)，发光层(24)，电子传输层(25)和阴极(26)通过真空沉积法在阳极(22)上形成。空穴传输层(23)，发光层(24)，以及阴极(26)和电子传输层(25)的表面可以设置有相应的不平坦部分，阳极的凹凸形状(22)被反映出来。因此，与迄今为止的例子的S0相比，发光层(24)的有效发光面积S1增加。平坦化绝缘层，发光层，电子传输层，真空沉积方法。

